Nature and sources of

Röntgen radiation

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Lectures course for Ph.D. studies at the IMIM PAN in the summer semester of the 2011/2012 academic year Subject: Characterization of materials structure by X-ray diffraction techniques Lecturer: Jan Bonarski, Ph.D, D.Sc., professor at Polish Academy of Sciences Internet survey of the lectures: http://anizo.imim.pl/wiki/dl/jan_bonarski_wyklad_i_mmn_2009.pdf http://anizo.imim.pl/wiki/dl/jan_bonarski_wyklad_ii_mmn_2009.pdf

- 1. Nature and sources of the X-rays
- 2. Diffraction phenomenon of X-ray
- 3. Crystallography and diffraction
- 4. Crystallographic texture
- 5. X-Ray Texture Tomography
- 6. Texture analysis of polycrystalline materials
- 7. Using X-ray diffraction in materials engineering

8. X-ray phase analysis, other useful methods and the newest achievements in the field of X-ray diffraction

9. Demonstration of experimental set up and measurement procedures in the X-ray Laboratory

10. Final colloquium

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Sources of Röntgen radiation

two phenomena which generate the X-rays:

[1] Electron transitions

[2] Change of momentum of the elementary particles (electrons)

Universum [1 + 2 + black holes] Environment of plasma generation [1] Thermo-nuclear reactions [1 + 2] X-ray tubes [1] Synchrotron [2]



X-ray tubes

- traditional way of inducing the Röntgen radiation

X-ray tube





Electron configuration of Cu-atom: 1s²2s²p⁶3s²p⁶d¹⁰4s¹

4s¹

 $3d^6$

 $3d^4$

3p

 $3p^2$

 $3s^2$

.... 18 states (2-"s", 6-"p" and 10-"d") for the electron quantum number n = 3, and so on.

K

Ι,

M

 \mathcal{N}

n (1, 2, 3...) <u>principal</u> quantum number (reflects the complete wave length of the electron on its orbit with r-radius) using to estimate the electron energy.

I (s, p, d...) <u>marginal</u> quantum number (introduced for non-circular orbits) reflects the orbital moment of momentum: s - relates to l = 0, p - to l = 1, d - to l = 2,...). l = 0, 1, 2, 3... n-1

 $1s^2$

 $2p^2$

 $2s^2$

<u>Additional</u> two quantum numbers m and s are required for a complete description of the electron state in the atom: m - magnetic quantum number regards a various orientation of the orbital which corresponds to specific movement state: m = -1, (-1+1), ..., 0, +1, +2, ..., +l.

S - spin quantum number of electrons: $s = \pm \frac{1}{2}$



Characteristics:

- white radiation
- tube output (actual)
- focus (point/line)
- cooling system



kinetic enery of elektron =
$$eV = \frac{1}{2}mv^2$$

kinetic enery of elektron =
$$eV = \frac{1}{2}mv^2$$

extremal case : $eV = hv_{max}$
 $\lambda = \frac{c}{v}$
 $\lambda_{min} \equiv \lambda_{SwLS(KGW)} = \frac{c}{v_{max}} = \frac{hc}{eV}$
 $\lambda_{SwLS(KGW)} = \frac{(6.626 \times 10^{34})(2.998 \times 10^8)}{(1.602 \times 10^{-19})V}$ [m]
 $\lambda_{SwLS(KGW)} = \frac{12.4 \times 10^3}{V}$ [Å]

Short-wave limit of spectrum (krótkofalowa granica widma)

 12.4×10^{3} [Å] λ_{KGW}





Intensity of the characteristic X-ray of *i-th* element, generated by electrons in excited, micro-volume area of massive material is proportional to contcentration of the element and depends on a depth-distribution of the emission effect

$$I_{i} = n_{0}C_{i}\int_{0}^{\infty}\varphi_{i}(\rho z)d(\rho z)$$

 n_0 – number of electrons falling down on sample, C_i – concentration of *i-th* element in sample, $\varphi_i(\rho z)$ – induction distribution function of X-ray of the *i-element* in materials

Base of X-ray microanalysis

Moseley law ($\lambda \sim 1/Z$) allow to explain the sequence of elements in periodic system which is based on the <u>atomic number</u> (Z) not <u>mass</u> number (M). For that reason, eg. cobalt (Z_{co} =27) proceeds nickel (Z_{Ni} =28), in spite of M_{co} (58.93) > M_{Ni} (58.69)



linear absorption coefficient $\sigma n \equiv \mu$:

 δI

 σ - (collision) cross-section for scattering and absorption of fotons is independent of material density and thats why the **mass absorption coefficient** can be easily expressed in a form: $\sigma N/A \text{ or } \mu \rho$



Absorption edge



 σ -(collision) cross-section for scattering and absorption of fotons <u>depends</u> on the photon energy and thats why the **filtering** of the spectrum components is possible, e.g. filter of *K* β -component (Ross's filter K α_1 -K α_2) Absorption edge



wavelength

Principle of filtering the K β -component , $K\alpha : K\beta z 5:1 do 600:1$







Radiation energy

Exemplar wavelengths of the characteristic lines [Å] (by. Int. Tabl. Cryst. V. III):

Material	$K\alpha_2$	<u>Κα</u>	<u> </u>	<u>filter of Kβ₁ comp.</u>
Cr (24)	2.29351	2.28962	2.08480	<i>wanadium</i> (23) [0.016 mm]
Fe (26)	1.93991	1.93597	1.75653	<i>manganese</i> (25) [0.016 mm]
Co (27)	1.79278	1.78892	1.62075	<i>iron</i> (26) [0.018 mm]
Cu (29)	1.54433	1.54051	1.39217	<i>nickel</i> (28) [0.021 mm]
<i>Mo</i> (42)	0.71354	0.70926	0.63225	<i>zirconium</i> (40) [0.108 mm]

Properties of X-ray (Röntgen radiation) (electromagnetic wave)

- scattering (coherent and fluorescent)
- absorption (attenuation in material medium)
- refraction (air solid body; $1-n = 10^{-6}$) (załamanie)
- total reflection ($q = 10' \div 30'$)
- magneto-"optical" Kerr effect

Miniature X-Ray Generator with Pyroelectric Crystal



AMPTEK INC. 6 De ANGELO DRIVE, BEDFORD, MA 01730-2204 U.S.A. *Tel:* +1 (781) 275-2242 *Fax:* +1 (781) 275-3470 *email:* sales@amptek.com www.amptek.com

Battery Operated

World's Smallest

APPLICATIONS

- Portable X-Ray Instrumentation
- Teaching Laboratories
- Instrument Calibration
- Research

FEATURES

• Miniature size - 0.6" dia x 0.4"

15 mm dia x 10 mm

- Low Power: <300 mW
- Runs on a standard 9 V battery
- ${\, \bullet \,}$ Variable end point energy: up to 35 kV
- Peak X-Ray flux: 108 photons per second (equivalent to a 2 mCi source)
- Solid state: Pyroelectric Crystal
- No radioactive sources





The COOL-X is a novel, miniature X-ray generator which uses a pyroelectric crystal to generate energetic electrons that produce X-rays in the target material (Cu). The hermetically sealed package has a thin beryllium window which allows the X-rays to be transmitted. The COOL-X does not use radioisotopes or high power X-ray tubes. It is a self contained, solid state system which generates X-rays when the crystal is thermally cycled.

The COOL-X is unique, and should not be compared with other X-ray tubes. It is thermally cycled between 2 to 5 minutes, and does **not** produce a constant flux of X-rays. The X-ray flux varies throughout the cycle and may vary from cycle to cycle, see Figure 4. The use of the COOL-X in practical applications will challenge the user's imagination! Miniature X-Ray Generator with Pyroelectric Crystal

COOL-X Output Spectrum from Cu Target



Miniature X-Ray Generator with Pyroelectric Crystal



COOL-X shown with the Amptek XR-100CR X-Ray Detector in an XRF application



Metal-Jet X-ray Source – How does it work?



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World-wide localization of synchrotron laboratories















X-rays

thickness of coatings, keeping the horizontal level

X-ray litography

patterns on Si-plates

Neutralization of electrostatic charges

in manufacturing the paper and plastics

X-ray Astronomy

observation of universum

Industrial radiography

safety of exploitation, quality control

Investigation of fast phenomena

flash inspection in synchrotron

Food production

detection of forein bodies, preservation

Sterilisation

medical tools/materials

Public security

ilumination of passangers/baggage, terrorism prevention

Archeology

non-destructive inspection of historic objects

Based on "Kalendarz Politechniki Opolskiej", 2012

Radiogram lilii oraz anturium wykonany przez D. Taskera w 1937 r. (zaczerpnięto z http://www.flickr.com)



Radiogramy kwiatów Merrilla C. Raikesa [15]







Wybrane radiogramy dużych obiektów technicznych - Nick Veasey [22]
Aracor's Eagle²





Cocaine hidden near rear window well and quarter panel





Stowaways hidden amongst cargo

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X-ray scattering by a free atom



Size of atom <u>can not be neglected</u>; electrons are not concentrated in one point! For that reason the scattered wave is summarized over all electrons in atom, regarding amplitudes and phases of individual waves



Fine-Structure Constant

Arnold Sommerfeld:
$$\alpha = \frac{e^2}{\hbar c \ 4\pi\varepsilon_0} = 7,2973525698(24) \times 10^{-3} = \frac{1}{137,035999074(44)}$$

e – electron charge

$$\hbar = h/(2\pi)$$
 – Planck constant
c – light velocity
 ε_0 – permitivity of free space (przenikalność elektryczna próżni)

$$lpha pprox 1/137$$
 ($lpha pprox 1/128$ for energy = particle mass)



By watching the far distant quasars the astronoms can to register a primeval light

The world-largest radiotelescope $(\emptyset 40m)$ with moving focusing cap:

Green Bank (West Virginia, USA)

New project: summarized area of the focusing cap = **1 km²** (Australia, 2012-2015):





X-ray diffraction phenomenon. Part I

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Diffraction theories of X-ray on condensed matter



describes **only directions**, in which the diffracted rays are observed (no intensity predictions)

describes (among others) <u>intensity</u> of radiation and is correct in the case of defected and relatively fine-grained materials to fulfil relation: $I_{(scattered)} \ll I_{(diffracted)}$. No extinction is regarded

Describes diffraction on materials with enough large areas of coherent scattering with *L* dimmension ($\mu L > 0.01$)



Powstawanie nowej powierzchni falowej jako obwiedni fal cząstkowych Christian HUYGENS (1629-1695), 1678: <u>outline of light theory</u>

<u>HUYGENS</u> explained mechanizm of waves propagation

FRESNEL

1818: perturbation in any point is a result of interference of elementary waves regarding its amplitude and phase



Thomas **YOUNG** (1773-1829),

1802 carried out and explained the interference phenomena Estimated wavelength.

Other interests: elasticity of solid bodies (E modulus)

- for steel $E = 2.0 \times 100 \text{ ooo MPa}$
- for bronze $\mathrm{E}=1.0 \ \mathrm{x} \ 100 \ \mathrm{000} \ \mathrm{MPa}$
- for glass $E = 0.6 \times 100 \text{ ooo MPa}$







Effect of laser light diffraction on two slits

Scattered coherent waves:

Interference constructive

Interference destructive

Mathematical formulae: von Laue* (1912)



Max von LAUE (1879–1960), physiker, prof. univ. Zurich and Berlin, Discoverer of X-ray diffraction, Nobel Prize, 1914

Scattering on many atom layers in crystalline materials





Rys. 3.6. Lauegramy wykonane metodą: a) promieni przechodzących i b) promieni zwrotnych. Promieniowanie anody wolframowej 30 kV, 19 mA

X-ray scattering by a free electron

Kinematical theory of interference (Max von LAUE [1879 - 1960, discovered diffraction of X-ray on crystals)

Electromagnetic, polarized/unpolarized waves \rightarrow free electron \rightarrow secondary source of vibration:



X-ray scattering by a free atom Lorentz-

polarization

factor

Thomson factor (mass of nucleus can be neglected)

$$I_0 = I_0 \left(\frac{e^2}{mc^2}\right)^2 \frac{1}{R^2} \frac{1 + \cos^2 2\theta}{2}$$

Size of atom <u>can not be neglected</u>; electrons are not concentrated in one point! For that reason the scattered wave is summarized over all electrons in atom, regarding amplitudes and phases of individual waves



X-ray scattering by a free atom

S R B'S_o S electrical charge Phase difference (phase shifting): in **B** point: $\Delta \varphi = \frac{2\pi}{2} \Delta l \implies \Delta \varphi = \frac{2\pi}{2} \vec{r} \cdot \vec{S}$ $\rho(r)dve^{\frac{2\pi}{\lambda}i\bar{r}\cdot\bar{S}}$ Finally, <u>amplitude</u> of wave scattered in B point: <u>Amplitude</u> of wave scattered in all points (electrons) in \mathcal{E}_{t} directions) where $\rho(\mathbf{r})$ is a charge density in yoyal dy located in $f_{t}(S) = \int \rho(\mathbf{r}) e(\mathbf{r}) dv dv$

where $\rho(\mathbf{r})$ is a charge density in voxal dv located in r

X-ray scattering by a free atom

characterizes an <u>ability</u>

of atom to scattering X-rays. In other words: the numerical value *f* exhibits how many times the amplitude of wave scattered by an atom is <u>greater</u> than one of scatterd by a singular electron

$$f\left(\vec{S}\right) = \int_{V} \rho(r) e^{\frac{2\pi}{\lambda} i \vec{r} \cdot \vec{S}} dv$$

amplitude scattered by atom

amplitude scattered by elektron

atomic scattering amplitude for a <u>spherical</u> distribution of charge in atom:

$$f(\vec{S}) = \int_{0}^{\infty} 4\pi r^{2} \rho(r) \frac{\sin(\vec{r} \cdot \vec{S})}{\vec{r} \cdot \vec{S}} dv$$

The <u>greater</u> atomic number of element, the <u>greater</u> atomic amplitude. That's why, e.g. X-ray scattering by hydrogen is very poor $for \ \vec{S} \to 0, \ f(0) = \int_{0}^{\infty} 4\pi r^{2} \rho(r) dv \approx Z$



atomic scattering amplitude

Regarding the thermal oscillation of atoms (possible maximal ampl. \approx 0.1 Å):

$$f = f_0 e^{-M}$$

$$M = 8\pi^2 \overline{u}^2 \frac{\sin\theta}{\lambda}$$



- mean square oscillation of the atom from a balance position

Geometry of diffraction (but not intensities) can be expressed relatively clearly using the Bragg (Wulf-Braggs) low: Diffraction on a singular layer of regularly distributed atoms

 $\theta_{outgoing}$

Two coherent waves A and B are in phase (in consistency) (and reinforcing each other) giving a diffracted beam (bended beam), only when they travel the same distance, i.e. when x and y are equal:

x = y

This only occurs for scattered waves with an outgoing angle of:

incident

$$\theta_{outgoing} = \theta_{incident}$$





Case of many layers of regularly spaced atoms – as in crystal

As we alredy known: $\theta_{incidence} = \theta_{outgoing}$ How the coherent waves are scattered on many atomic layers?



Scattering on many atomic layers in crystal

For defined pair of d_{hkl} and λ there are a few values of diffraction angle θ_{hkl} predicted by the law (quite so!)



Bragg equation **?**

A basi



PROCEEDINGS THE ROYAL A

The Reflec By W. H. BRAGG, M.A., I University of Leeds ; Cambridge. (Received

In a discussion of the La may conveniently be interpreplanes within the crystal as attempt to use cleavage pla gives a reflected pencil from visible impression on a phothas also been observed tha ionisation method.[†]



FIG. 3.—Reflection (I) from face (100) and (II) from face (111) of rock-salt. The curves show the variation of strength of reflected beam with angle of incidence.

It is of great interest to attempt to find the exact wave-length of the rays to which these peaks correspond. On considering Curve I, fig. 3, it seems evident that the peaks $A_1 B_1 C_1$, $A_2 B_2 C_2$ are analogous to spectra of the first and second orders, because of the absence of intervening sets of peaks. The value of n in the equation

$n\lambda = 2d\sin\theta$

seems clear. The difficulty of assigning a definite wave-length to the rays arises when we attempt to determine the value of d, the distance of plane from plane.

* We learn that Messrs. Moseley and Darwin have lately been making experiments similar to some of those recorded here. Their results, which have not been published, agree with ours. reflection of X-rays in spectrometer in form, ope. The collimator is in be stopped down to the centre carries the n. long and 5 cm. in nstrument, to which its ur dioxide in order to l iodide have also been cteristics of the gas in

Part I, p. 43.

1915 (along

. of Kazań, the Science returned to

William Henry Univ. of Londo **1915** (along wi

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• in Russian lite

William Lawrai

...by Bragg: $n\lambda = 2d_{hkl}\sin\theta_B$ [Proceedings of the Royal Society, 1913, 88, 428]

Adnotation at the end of the work of H.W & W.L. Braggs from 1913: "Received April 7, 1913"

Gieorgij W. Wulf – two his works from beginning 1913 in Russian [Fizika, 1913, zesz. 1, s. 10 and Priroda, 1913, s. 27] concerned to interference of X-rays and its behaviour in passing through the crystals. *He known the earlier works of W.L. Bragg from 1912r.*

....by Wulf:

$$\frac{\lambda}{2} = \frac{\delta \varepsilon}{m}$$
"Ueber die Kristallroentgepogramme"
[Physikalishe Zeitschtriff, 1913], z. 6, s. 217]

where $\delta = d_{hkl}$, $\varepsilon = \cos \psi (\psi - angle between incident beam and normal to diffracting lattice plane), <math>m - order of reflection)$

$$m\lambda = 2d_{hkl}\cos\psi$$

Adnotation at the end of the work of G.W. Wulf (sent from Russia) from 1913: "Eingegangen 3 Februar 1913"

Base law (equation) of diffraction theory:

$$n\lambda = 2d_{hkl}\sin\theta_B$$

$$\frac{\lambda}{2} = \frac{\delta\varepsilon}{m}$$
$$m\lambda = 2d_{hkl}\cos\psi$$

Bragg law (equation)
Braggs law (equation)
Wulf law (equation)
Braggs – Wulf law (equation)

Wulf – Braggs law (equation)

Scattering on many atomic layers in crystalline materials



X-ray diffraction on polycrystalls

 $2\theta_B$

 $2\theta_B$

Polycrystal – definition

Debye cones



Petrus Josephus Wilhelmus Debije (after change: Peter Joseph William Debye) 1884 (Maastricht) – 1966 (USA)




Metoda Debye'a – Scherrera (Cullity, 1959): (a) geometria pomiaru, (b) wygląd rozwiniętego filmu.

Summary of the geometrical theory of diffraction:

delivers two equivalent conditions of diffraction phenomena:

• scalar – Bragg equation:
$$n\lambda = 2d_{hkl}sin\theta_{hkl}$$

• vector – Laue conditions: $\alpha(\cos\alpha - \cos\alpha_0) = H\lambda$

 $n \equiv H \rightarrow order \ of \ reflection$



Interaction of singular wave with a material particle (atom) - scattering



Interaction of singular wave with many material particles (atoms) – scattered waves interfering in a few directions, reinforcing each other = **diffraction**. Its possible on a <u>periodic structures</u> only



Remembrance: for understanding the diffraction geometry ($\lambda =$, amplitude =, $\phi \neq$) (superposition)



Interference of waves



component wave
component wave
product wave

Scattering X-rays on crystal



Scattering X-rays on crystal



Scattering X-rays on crystal

Difference of the wave phases scattered on **A** and **B** electrons:

$$\Delta \varphi = \frac{2\pi}{\lambda} \Delta l \implies \Delta \varphi = \frac{2\pi}{\lambda} \vec{r} \cdot \vec{S}$$

Because $\mathbf{r} = x\mathbf{a} + y\mathbf{b} + z\mathbf{c}$ (where x, y, z are coordinates of the atom in point \mathbf{B} expressed in fractions of the lattice periods $\mathbf{a}, \mathbf{b}, \mathbf{c}$) and $\mathbf{S} = \lambda \mathbf{H} (\mathbf{S}_1 - \mathbf{S}_0 = \lambda \mathbf{H})$, replacing: $\mathbf{H} = h\mathbf{a}^* + k\mathbf{b}^* + l\mathbf{c}^*$, (\mathbf{H} – vector perpendicular to diffracting plane hkl) the following relation can be written:

$$\Delta \varphi = 2\pi (hx + ky + lz)$$

Product amplitude from all atoms in the elementary lattice: $F = F_1 + F_2 + F_3 + \dots + F_n$

<u>Structure</u> amplitude, non-measurable directly

$$F = F_{hkl} = \sum_{j=1}^{n} f_j e^{2\pi i(hx_j + ky_j + lz_j)} \qquad I_{hkl} \sim F_{hkl} \cdot F^*_{hkl}$$
$$I_{hkl} \sim F^2_{hkl}$$

$$F = \sum_{1}^{2} A_{n} = f_{1} \exp(2\pi i (0 + 0 + 0))$$
$$+ f_{2} \exp(2\pi i (hu + kv + lw))$$

$$\exp(0) = 1$$

$$F = f_1 + f_2 \exp\left(2\pi i \left(hu + kv + lw\right)\right)$$

Various combinations of the *hkl* and *uvw* are possible which relfect in diversity of the *F* value:

F = 0 - no diffraction effect (impossible to registering) **F** = $f_1 + f_2$ - strong diffraction effect For *bcc* lattice, number of atoms deduces to TWO:

1 in 0,0,0 point (atomic scattering amplitude *f*),
2 in ½, ½, ½ point (amplitude *f*).



$$F = f + f \exp\left(2\pi i \left(\frac{h}{2} + \frac{k}{2} + \frac{l}{2}\right)\right)$$
$$= f\left(1 + \exp\left(\pi i (h + k + l)\right)\right)$$



$$F = f + f \exp\left(2\pi i \left(\frac{h}{2} + \frac{k}{2} + \frac{l}{2}\right)\right)$$
$$= f\left(1 + \exp\left(\pi i \left(h + k + l\right)\right)\right)$$

When diffraction occurs on the lattice for which h+k+l is odd (nieparzysta), the 2^{nd} term = -1;

$$\mathbf{F}_{hkl(niep.)} = f(1-1) = \mathbf{0}$$

When h+k+l is even (parzyste), the 2nd term = +1; $F_{hkl(parz.)} = f(1+1) = 2f$

<u>Conclusion</u>: in the case of X-ray scattering on **bcc** lattice, diffraction is not observed for the planes which h+k+l is odd, (forbidden reflections)

Dyfraktogram próbki stali głębokotłocznej pokrytej warstwą Zn (grubość ok. 7.5mikr.) Użyte promieniowanie: CoK-alfa (śr.). IMIM-PAN, Kraków, Czerwiec 2000



Intensity of diffraction effect $I_{(hkl)}$ at defined Bragg angle $\theta_{(hkl)}$ for homogeneous phase of powdered sample:

$$I_{(hkl)} = \left(\frac{I_0 A \lambda^3}{32\pi r}\right) \left[\left(\frac{\mu_0}{4\pi}\right)^2 \frac{e^4}{m^2}\right] \left(\frac{1}{v^2}\right) \left[\left|F_{(hkl)}\right|^2 p_{(hkl)} LP_{(hkl)}\right] \left(\frac{e^{-2M}}{2\mu}\right) \left[\frac{e^{-2M}}{2\mu}\right] \left(\frac{1}{v^2}\right) \left[\left|F_{(hkl)}\right|^2 p_{(hkl)} LP_{(hkl)}\right] \left(\frac{e^{-2M}}{2\mu}\right) \left[\frac{e^{-2M}}{2\mu}\right] \left(\frac{1}{v^2}\right) \left[\left|F_{(hkl)}\right|^2 p_{(hkl)} LP_{(hkl)}\right] \left(\frac{e^{-2M}}{2\mu}\right) \left[\frac{e^{-2M}}{2\mu}\right] \left(\frac{1}{v^2}\right) \left[\frac{1}{v^2}\right] \left[$$

where: I_0 - intensity of incident beam, A – cross-section of incident beamj [m³], λ - wavelength [m],

- r radius of diffractometer, μ_0 constant value, e- electric charge of electron [C], m mass of electron [kg],
- *v* volume of elementary lattice cell [m³], $F_{(hkl)}$ structure amplitude (structure factor), $p_{(hkl)}$ multiplicity of lattice planes {*hkl*}, *LP*_(hkl) geometrical, (Lorenz-polarization) factor, e^{-2M} Debye-Waller factor, μ liniear absorption coefficient [m⁻¹].

$$I_{(hkl)} = C I_0 \lambda^3 \left| F_{(hkl)} \right|^2 p_{(hkl)} L P_{(hkl)} \left(\frac{e^{-2M}}{\mu} \right)$$

where:

$$C = \frac{Ae^4 \mu_0^2}{1024\pi^2 m^2 v^2 r}$$

Indexing the crystallographic planes and directions



<u>Miller indicies</u> – are notation of the planes and directions defined in crystallographic lattice based on the elementary lattice cell.

<u>Crystallographic direction</u> – fractions of the basal vectors of the lattice cell [uvw], where u, v and w are complete numbers. The family of directions crystallographically equivalent <uvw>.

Crystallographic directions in 2-D orthogonal lattice



Miller indicies for <u>lattice planes</u> are expressed in form (hkl), where h, k, I are complete numbers indicate to how many parts of the basal periods a, b, c are divided by the plane

(na ile części dana płaszczyzna (najbliższa początku układu) dzieli podstawowe periody na osiach układu współrzędnych).

Family of crystallographically equivalent planes: {hkl}.

Miller indicies of a crystallographic plane



Basic families of the lattice planes



Rys. 16. Wskaźniki ważniejszych płaszczyzn kryształu o strukturze regularnej. Płaszczyzna (200) jest równoległa do płaszczyzn(100)i $(\bar{1}00)$

(100) (010) [111] (001) (110) (1, -1, 0)(-1, 1, 0)[010] (111) y С {111} 0 A b[100] ${\mathcal X}$



X-ray diffraction phenomenon. Part II

Jan T. Bonarski



Instytut Metalurgii i Inżynierii Materiałowej im. Aleksandra Krupkowskiego POLSKIEJ AKADEMII NAUK w Krakowie



Indexing the crystallographic planes and directions



<u>Miller indicies</u> – notation of the planes and directions defined in crystallographic lattice based on the elementary lattice cell.

<u>Crystallographic direction</u> – fractions of the basal vectors of the lattice cell [uvw], where u, v and w are complete numbers. The family of directions crystallographically equivalent <uvv>.

Crystallographic directions in 2-D orthogonal lattice



Miller indicies for <u>lattice planes</u> are expressed in form (hkl), where h, k, I are complete numbers indicate to how many parts of the basal periods a, b, c are divided by the plane

(na ile części dana płaszczyzna (najbliższa początku układu) dzieli podstawowe periody na osiach układu współrzędnych).

Family of crystallographically equivalent planes: {hkl}.

Crystalline body – condensed matter with 3D ordered structure.

Properties od crystals: <u>electrical, magnetical, optical and mechanical</u>, contrary to <u>amorphous bodies</u>.

Single (mono)- or Polycrystals

Single crystals: mono-phase, non-defected crystalline body, eg.:

- **sapphire** $(Al_2O_3 + small amount TiO_2 and Fe_3O_4)$
- **ruby** $(Al_2O_3 + small amount Cr_2O_3)$

Polycrystal: conglomeration of single crystals (micro-meter dimension)

Elementary cell

Ideal- and real crystals

Spatial lattice – infinit conglomeration of ideal elementary cells Lattice nods – points of intersection of edges of the elementary lattice. Lattice lines – lines indicated by selected lattice nodes. Lattice planes – planes indicated by the selected lattice nodes. Crystal structure – way of distribution of atoms (ions, particles) in elementary cell.



Regarding the values of lattice constants of the crystals and symmetry of spatial lattice 6(7) various *crystallographic systems* have been defined. Lattice periods *a*, *b*, *c* and angles α , β and γ .

An elementary cell which translation $a \overline{long X}$, Y, Z reconstruct whole spatial lattice can be distinguished in each of the crystallographic system.

Cells: *primitive* **P**, *centered*: **C** (on basal planes), **F** (face-centered), **I** (spatial-centered) Each of the *6*(7) crystallographic system, dependig on its symmetry, have a strictly defined number of the elementary cells. As it was prooved, there are *14* various cells – *Bravais cells*

TRICLINIC MONOCLINIC RHOMBOHEDRAL = ORTHORHOMBIC

TRIGONAL

(describing analogically to hexagonal)

TETRAGONAL HEXAGONAL \equiv *RHOMBOHEDRAL* REGULAR

Crystallographic system: **REGULAR** $a_0 = b_0 = c_0$ $\alpha = \beta = \chi = 90^\circ$

Bravais cells:

P (putibolding e) e^{h} tenated fcc, A1)



Table 19. PERIODIC TABLE OF THE FACE CENTERED CUBIC ELEMENTS

1 IA	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18 VIIA
	IIA											IIIA	IVA	VA.	VIA	VIIA	
																	10 Ne
		ШВ	IVB	VB	VIB	VIIB		vш		IB	ΠВ	13 Al	14 Si				18 Ar
	20 Ca								28 Ni	29 Cu			32 Ge				36 Kr
	38 Sr							45 Rh	46 Pd	47 Ag							54 Xe
								77 Ir	78 Pt	79 An			82 Pb				86 Rn

57 La							
89 Ac							

			Table 18. PERIODIC			TAB	TABLE OF THE BODT CENTERED CUBIC ELEMENTS								3		
1 IA	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18 VIIA
	IIA											IIIA	IVA	VA	VIA	VIIA	
3 Li																	
11 Na		ПІВ	IVB	VB	VIB	VIB		VШ		1B	пв						
19 K				23 V	24 Cr	25 Mn	26 Fe										
37 Rb				41 Nb	42 Mo												
55 Cd	56 Ba			73 Ta	74 W												
87 Fr	88 Ra				· · · · ·												
			I														

ort a s DEDIODIC TABLE OF THE DODY CENTERED CUBIC FURNERS

			63 Eu				

Crystallographic system: TETRAGONAL

$$a_0 = b_0 \neq c_0 \qquad \alpha = \beta = \chi = 90^\circ$$

Bravais cells: **P** (**b**(**b**) three **b**)



Tetragonal:eg. corundum, quartz,turmalinum, α -Fe_martensite

Crystallographic system: **RHOMBOHEDRAL** $a_0 \neq b_0 \neq c_0$ $\alpha = \beta = \chi = 90^\circ$

Bravais cells:

P (privative entertailanes (factored) ered)



Rhombohedral: eg. topaz, aragonite (variant of $CaCO_3$, eg. Conus Marmoreus)
Crystallographic system: MONOCLINIC $a_0 \neq b_0 \neq c_0$ $\alpha = \gamma = 90^\circ$, $\beta \neq 90^\circ$

Bravais cells: P (primitive(basal-planes centered)



Monoclinic: eg. cellulose (crystalline part), jade (nefryt)

Crystallographic system: TRICLINIC

$$a_0 \neq b_0 \neq c_0 \qquad \alpha \neq \beta \neq \gamma \neq 90^\circ$$

Bravais cells: **P** (primitive)



Triclinic: eg. turquoises (turkus), amazonite

Crystallographic system: HEXAGONAL



$$a_0 = b_0 \neq c_0$$
 $\alpha = \beta = 90^\circ$, $\gamma = 120^\circ$

hcp (hexagonal close packed)

$$c_0 / a_0 = 1.633$$

				Table	21. PE	RIODI	C TAP	BLE OF	THE	HEXA	GONA	t Ete	MENT	S			
1 IA	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18 VIIA
	ПА											IIIA	IVA	VA	VIA	VIIA	
													6 C				
		ШВ	IVB	VB	VIB	VIB		νш		IB	пв						
															34 Se		
															52 Te		
																-	

57 La	59 Pr	60 Nd	61 Pm						
				95 Am	96 Cm	97 Bk			

				and a second from the	and a second second second				and the device the	ar an the state and	There's data in the of the of the						
1 IA	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18 VIIA
	ПА											ША	IVA	VA	VIA	VIIA	
	4 Be																
	12 Mg	ШВ	IVB	VB	VIB	VIIB		VШ		IB	IIB						
			22 Ti					27 Co			30 Zn						
		39 Y	40 Zr			43 Tc	44 Ru				48 Cd						
			72 Hf			75 Re	76 Os					81 Tl					
					•				•							•	
								~ 4		مر مر			~~			1	

Trable 20. PERIODIC TABLE OF THE HEXAGONAL CLOSE PACKED ELEMENTS

			64 Gd	65 Tb	66 Dy	67 Ho	68 Er	69 Tm	71 Lu

Crystallographic system: HEXAGONAL

A9 (graphite type structure)

typical layered structure

$$c_0 / a_0 = 2.76$$

Allotropic variety of carbon:

- **Diament** (regular + hexagonal)
- **Graphite** β (rhombohedric = hexagonal)
- Fulerens C_{60} (since 1985r)
- Graphene (since 2010r)



Graphite-type structures – strong anizotropy of properties: cleavage (łupliwość), thermal expansion, electric conductivity

 $a_0 = b_0 \neq c_0$ $\alpha = \beta = 90^\circ$, $\gamma = 120^\circ$ Crystallographic system: TRIGONAL

describing

RHOMBOHEDRAL $a_0 = b_0 = c_0$ $\alpha = \beta = \gamma \neq 90^\circ$

280usly to hexagonal

Bravais cells: P (primitive)

Rhombohedral: eg. graphite β

TRICLINIC

MONOCLINIC

describing available of the second **DHEDRAL** \equiv ORTHORHOMBIC

(describing analogically to hexagonal)

TETRAGONAL

HEXAGONAL = RHOMB

REGULAR

by. Int. Tabl. Cryst., 6 crystallographic families and 7 crystallographic systems

α -corundum α -Al₂O₃

-Rhembehedral Hexagonal lattice (R-3c): $a_0 = 4.7580$ Å, $c_0 = 12.9910$ Å, $\alpha = \beta = 90^\circ$, $\gamma = 120^\circ$



50 × 50 × 8 mm³

silicon carbide SiC

Hexagonal lattice (P63mc): $a_0 = 3.0810 \text{ Å}, c_0 = 10.0610 \text{ Å}, \alpha = \beta = 90^\circ, \gamma = 120^\circ$



50 × 50 × 10 mm³

Miller-Bravais Indicies

In 3-digit Miller's notation (planes and directions) for <u>hexagonal</u> <u>system</u> the crystallographicaly equivalent planes have various indicies. The inconvenience is not exists in 4-digit Miller-Bravais notation.

<u>Plane</u> (HKiL), where *H*, *K*, *i* and *L* are complete K = knumbers, where i = -(H + K) i = -(h + k)

L = I

H = h

Direction expressed as **[UVTW]** where *U*, *V*, *T* and *W* are complete numbers, additionally T = -(U + V), ...but indicies of directions <u>can not be derived directly</u> from the equivalent Miller indicies

U = (2u - v)/3 V = (2v - u)/3 T = -(u + v)/3W = w

Crystallographic system: HEXAGONAL $a_0 = b_0 \neq c_0$ $\alpha = \beta = 90^\circ$, $\gamma = 120^\circ$

Bravais cells:

P (primitive)

 $c_0 / a_0 = 1.633$









Zn, Cd, Mg, Co, Ti, Zr

Planes:

• basal,

• prismatic,

• pyramidal





W układzie heksagonalnym \rightarrow analogicznie, ale użyć 3-wskaźnikowego zapisu

Idea of reciprocal lattice



Reciprocal lattice is defined by 6 parametrs, and given equations – using parameters of the real space – allow to calculate the length of vectors:

$$\overline{a^*} = \frac{\overline{b} \times \overline{c}}{\overline{a}(\overline{b} \times \overline{c})} \qquad a^* is \beta$$

$$\overline{b^*} = \frac{\overline{c} \times \overline{a}}{\overline{a}(\overline{b} \times \overline{c})} \qquad b^* is \beta$$

$$\overline{b^*} = \frac{\overline{c} \times \overline{a}}{\overline{a}(\overline{b} \times \overline{c})} \qquad c^* is \beta$$

$$\overline{c^*} = \frac{\overline{a} \times \overline{b}}{\overline{a}(\overline{b} \times \overline{c})} \qquad c^* is \beta$$

$$\overline{a(\overline{b} \times \overline{c})} = V$$

$$\overline{a(\overline{b} \times \overline{c})} = V$$

$$\cos \alpha^* = \frac{\cos \beta \cos \gamma - \cos \alpha}{\sin \beta \sin \gamma}$$

$$\cos \beta^* = \frac{\cos \alpha \cos \gamma - \cos \beta}{\sin \alpha \sin \gamma}$$

$$\cos \gamma^* = \frac{\cos \alpha \cos \beta - \cos \gamma}{\sin \alpha \sin \beta}$$

γ

s perpendicular to **b** and to $\mathbf{c} \rightarrow \mathbf{a}^* \cdot \mathbf{b} = \mathbf{a}^* \cdot \mathbf{c} = \mathbf{0}$

s perpendicular to **c** and to $\mathbf{a} \rightarrow \mathbf{b}^* \cdot \mathbf{a} = \mathbf{b}^* \cdot \mathbf{c} = \mathbf{0}$

perpendicular to **a** and to **b** \rightarrow **c**^{*} \cdot **a** = **c**^{*} \cdot **b** = **0**

V – volume of elementary cell of the real lattice, defined by vectors

Properties of reciprocal lattice

EWALD's construction

Peter Ewald publication (in 1913) of geometrical construction for interpretation of diffraction patterns.







"Ueber die Kristallroentgenogramme" [Physikalishe Zeitschtrift, 1913, J. 6, s. 217] gdzie $\delta = d_{hkl}$, zaś $\varepsilon = \cos \psi (\psi - kqt pomiędzy wiązką padającą a normalną do płaszczyzny uginającej), m – rząd refleksu)$

Odkrycie dyfrakcji promieni rentgenowskich (M. von LAUE), Nagroda Nobla 1914r. Początek I-wszej Wojny Światowej 1914r



When the beam is fallig down on crystal, the <u>Ewald's sphere</u> indicates exactly the lattice planes (families) which fulfill <u>Bragg's diffraction condition</u>. For a 2D-lattice, the Ewald's sphere is a circle.





Diffraction on 3D-lattice





SADP electron diffractions from melt spun NiTiZr ribbons

Anomalous X-ray scattering

→ Application in identification of early stage of precipitation (ASAXS)



related to the Co precipitates can be separated (b).

X-Ray Texture Tomography



Jan Bonarski

Polish Academy of Sciences *Aleksander Krupkowski* Institute of Metallurgy and Materials Science Kraków, POLAND http\\www.al.imim-pan.krakow.pl **X-ray texture tomography** is a new, non-destructive method of th investigation of the near-the-surface layers of the sample.

The method is based on single-layer pole figures, which are two dimensional density distribution of poles of the lattice planes, referred t the near-the-surface layer of precisely defined thickness.

Because some of the elements of this procedure are similar to the know techniques of spatial imaging of objects localised inside some definit volume, such as <u>magnetic-resonance tomography</u>, <u>seismic tomography</u>, <u>copositron emission tomography</u>, the introduced described investigatio method has been called X-ray texture tomography.

In this newly introduced concept the meaning of the commonly use expression "**tomography**" becomes extended, as it refers to the imaging of a material feature, as represented by texture, and not to material object (e.g. accumulation of tissues).

Texture tomography represents a research tool, which may be applied i the analysis of texture inhomogeneity, its heredity, the control of th

Investigation of crystallographic texture:

How?

Electron, x-ray and neutron diffraction techniques (SEM, TEM, EBSD, OIM, XRD, ND), Optical observations,

What for?

- For controlling of technological processes,
- For understanding the "natural construction" of materials and it application in technology
- For knowing of geological history of the Earth,
- For archeological/medical expertises (texture of animal/human bones)

Crystallographic texture:

What is it?

a statistical feature of polycrystalline materials, manifests by preferred crystallographic

orientation of grains, particles or distinguished sub-areas. **Sources of texture**

- natural anisotropy of crystals (determined crystal symmetry),
- technological processing of materials (crystallization, deformation)
- Nature (seismic vibration of Earth, "architecture" of plants, selective synthesis of proteins)

Is the texture <u>advantage</u> or <u>disadvantage</u> of materials?

Yes

deep drawing steel <111> electromagnets transformators (Fe + 3%Si) photovoltaics (Si-multicrystalline solar cells) superconductivity

No

.

structure inhomogeneity diffraction phase identification/analysis Problems of samples standardization electrodepositing (inheritance effect) From application point of view, the properties (structure and texture) of a relative thin, near-the-surface layers of constructing elements play a very important role.

Examples:

- Elements working in friction and fatique conditions (bearings),
- •Deposited coatings,
- Solar cells.



Microstructure of the broken cross-section of (001)-oriented Si single crystal after implantation (P^+ ions) and subsequent thermal treatment, registered by means of contact AFM technique.



Microstructure of the cross section of deep drawing steel sheet with deposited Zn-protective layer (thickness of 7.5 μ m) observed in SEM [IMIM PAN, Kraków]



Effective information depth X_{99%}



Length of beam in sample material

Changes of information depth

During texture analysis based on the back-reflection pole figures registered by means of x-ray diffraction, information depth $\{X_{0.01}\}$ changes with the sample position in goniometer, determined by the θ , χ angles.






Geometrical conditions of measurement at constant information depth (CID)

The information depth $\{X_{0.01}\}$ can be controlled and kept at the constant level by: • changes of wavelength,

• introducing an additional goniometer angle ω:

$$X_{0.01} = -\frac{\ln(0.01)}{\mu} \cdot \frac{\sin(\theta + \omega) \cdot \sin(\theta - \omega)}{\sin(\theta + \omega) + \sin(\theta - \omega)} \cdot \cos \chi$$

where, the geometrical factor $\xi(\theta, \omega, \chi)$

$$\xi = \frac{\sin(\theta - \omega) + \sin(\theta + \omega)}{\sin(\theta + \omega) \cdot \sin(\theta - \omega)} \cdot \frac{1}{\cos \chi}$$

determines the condition of registration of the <u>pole figure with constant</u> <u>information depth</u>, termed here as a <u>single-layer pole figure</u>.

Information valley of X-ray CoK α radiation in *Al* sample for the *311* Bragg reflection.



The izo-depth lines correspond to the geometrical conditions (goniometer angles of sample tilting ω and χ) for registration of **15µm, 22µm** and **68µm** single-layer (311) pole figures.

Consequences of introducing the additional sample tilting angle ω

- desymmetrization of focalization conditions (offset from Bragg-Brentano geometry),
- deformation of the peak profile and the pole figure coordinates,
- necessity of mathematical transformation to the symmetrical system,
- arising of blind areas in experimental data,
- necessity of additional geometrical correction of the registered pole figures.





Experimental verification of the X-Ray Texture Tomography (XTT)

has been performed on a model sample of layered structure with accurately defined and known texture inhomogenity.



standard Al sample



Set of (111) back-reflection pole figures for the standard sample Al with inhomogeneous texture (CoKα radiation used):

- a) registered traditionally (information depth: 44.5 μ m 11.5 μ m),
- b) figure of top layer only (constant information depth, ca. 15.0 μ m),
- c) diference between the (a) and (b) case.



Identified texture components, volume fractions and inhomogeneity degrees for the standard Al sample, based on diffraction of $CoK\alpha$ and $CoK\beta$ x-ray beams.

No of com pone nt	Euler angles of component			Volume fractions of the components [% obj.] and they degree of inhomogeneity DI						Miller indiana of
				Sample areas subjected to diffraction of $CoK\alpha \& CoK\beta$			Separated layers <i>T</i> = top layer <i>B</i> = Bulk			texture component
	φ ₁ []	Ф []	φ ₂ []	Co <i>Kα</i> [%vol]	Co <i>Kβ</i> [%vol]	DI	<i>T</i> [%vol]	B [%vol]	DI	(hkl)[uvw]
1	31.1 2	36.7 0	26.5 7	42.2	45.1	0.1	52.7	0.0	2.0	~ (122)[21] S'
2	0.00	35.2 6	45.0 0	23.7	26.9	0.1	18.4	0.0	2.0	(112)[10] <i>Copper'</i>
3	58.9 8	36.7 0	63.4 3	9.7	11.0	0.0	0.0	34.2	2.0	(132)[63] S
4	90.0 0	35.3 6	45.0 0	7.5	8.5	0.1	0.0	18.4	2.0	(112)[11] Copper
5	35.2 6	90.0 0	45.0 0	5.4	5.2	0.1	5.2	0.7	1.5	(110)[11] <i>Brass'</i>
6	54.7 4	90.0 0	45.0 0	2.6	2.7	0.0	0.8	5.3	1.5	(110)[12] <i>Brass</i>
7	0.00	0.00	0.00	1.4	1.1	0.2	4.9	4.9	0.0	(001)[100] <i>Cube</i>
The rest				~ 7	~ 0		~ 18	~ 35		
Background				0	0		0	0		



Expected (simulated) texture:

$$\overline{f}(g) = (1 - A) \cdot f_1(g) + A \cdot f_2(g)$$

Weight factor: $\ln \varepsilon \cdot \frac{x_{w}}{X_{\varepsilon}}$ $A = e^{-\mu \cdot \xi \cdot X_{w}} = e^{-\sum_{w \in X_{\varepsilon}} x_{\varepsilon}}$

 X_W – thickness of top layer (ca. 15 µm)

 X_{ε} – thickness of the chosen near-the-surface layer (15 µm, 22 µm, 68 µm,)



Verification of X-ray texture tomography





Texture tomography of Zn corrosion-protective layer (thickness of 7.5 μm), deposited on deep drawing steel by electrodeposition technique.

Presented texture functions $(\phi_2=45^\circ \text{ sections})$ of Fe-Zn composition:

Par-surface layer (5.0 μm) obtained by x-ray texture tomography,

averaged texture (7.5 μm) of Zn layer obtained by the backreflection pole figures measured conventionally.

 substrate (ferritic deep-drawing steel)



Single-layer pole figures with corprocedure for reference Al sample, obtained by x-ray texture tomography. Calculated from ODF by ADC method (bottom). The *hkl* indices corresponds to the measured reflections.



Orientation distribution function (ODF) for the near-surface layer of $22\mu m$ thickness, of reference Al sample, obtained by x-ray texture tomography.

Single-layer pole figures with cor procedure for reference Al sample, registered by gomometer (top), manematically transformed (integer), and calculated from ODF by ADC method (bottom). The *hkl* indices corresponds to the measured reflections.

Texture tomography of HfN layer (thickness of 0.5 µm), deposited on Si (111)-oriented single crystal by the reactive sputtering technique.

Presented texture functions -150 continual concorr

Averaged texture of HfN layer, obtained by means of the conventional back-reflection pole figures.



0DF N 9

20

0

X-Ray texture tomography represents a new, non-destructive method of the investigation of the near-the-surface layers of the sample.

It is research tool, which may be applied in the analysis of texture inhomogeneity, its heredity, the control of the process of multi-layered structures etc.

Another possible applications the constant information depth (CID) measurement technique:

• deep-profile of phase volume fraction (<u>phase volume tomography</u>)

• deep profile of residual stresses (stress tomography)

Useful methods and the latest achievements in X-ray diffraction

Jan T. Bonarski

X-ray phase analysis

Identification of Fe structure

[4 phases: *α*, *β*, *γ*, *δ*?]



---->

Dwie techniki pomiarów dyfraktometrycznych stosowane szczególnie w badaniach materiałów o strukturze krystaliczno-amorficznej (polimery):





destructed layer

surface

amorphized buried layer

non-destructed bulk of crystal



The 3-D distribution of the line profiles intensity (in logarithmic scale) for **351** reflection of the $\langle 001 \rangle$ oriented Si single crystal solar cell with the buried amorphized and porous silicon layers. Registration was performed for 8KeV synchrotron beam at constant azimuthal angle {*beta*}. [IMIM PAN, Kraków & Synchrotron Lab. *ELETRA*, Trieste, 1999]

$mod \ 2\theta - scan$





skanowanie sieci odwrotnej po sferze Ewalda



destructed amorphized buried

> non-destructed bulk of crystal

mod *a* – scan ("rocking curve")





Rocking angle (ω)



Size of crystallites

Lattice distortion





Figure 3. Aline out of the emission spectrum from an x-ray laser experiment shows that the 14.7-nanometer x-ray laser line is orders of magnitude brighter than any other emission line.

Rtg. Laser








Free Electron Laser oznacza laser na swobodnych elektronach.



FREE ELECTRON LASERS			SERS
LOCATION	NAME	WAVELENGTHS	TYPE
FELI (Japan)	3 2 1 4 5	0.23 - 1.2μm 1 - 6μm 5 - 22μm 20 - 60μm 50 - 100μm	linac
FOM (Netherlands)	FELIX1 FELIX2	5 - 35μm 20 - 110μm	linac
Vanderbilt TN (USA)	MK-III	2.2 - 9.6µm	linac
Duke NC (USA)	MK-III OK-4	1.5 - 9.5μm 340 nm	linac storage ring
Stanford CA (USA)	SCA-FEL FIREFLY	3-10μm 15-65μm	sc-linac
UCSB CA (USA)	FIR-FEL MM-FEL 30µ-FEL	63 - 340μm 340μm - 2.5 mm 30 - 63μm	electrostatic
LURE - Orsay (France)	CLIO Super-ACO	3 - 50μm 350 nm	linac storage ring
ENEA - Frascati (Italy)		1 mm - 600µm	linac
LANL NM (USA)	AFEL RAFEL	4 - 8µm 16µm	linac
Grumman/Princeton NJ (USA)	CIRFEL	8 - 20µm	linac
CEA - Bruyeres (France)	ELSA	18-24µm	linac
ETL - Tsukuba (Japan)	NIJI-IV	350 nm	storage ring
IMS - Okazaki (Japan)	UVSOR	300 nm	storage ring
ILE - Osaka (Japan)		47µm	linac
ISIR - Osaka (Japan)		40µm	linac
Darmstadt (Germany)	IR-FEL	6.8 - 7.8µm	sc-linac
IHEP (China)	Beijing FEL	10µm	linac

ZASTOSOWANIE LASERÓW RENTGENOWSKICH

- Diffraction
 - <u>Magnetism</u>
 - Surface and Interface Science
 - High Pressure Work
 - Material Science
 - <u>Soft Matter</u>
 - Biology
- Nuclear Resonant Scattering
 - Expected Impact
 - Biology
 - Nuclear Physics
- <u>Spectroscopy</u>
 - <u>X-ray Absorption Spectroscopy</u>
 - X-ray Standing Waves
 - Surface Studies.
 - Extremely Dilute Systems.
 - Atomic Physics
 - <u>Scattering</u>
 - Inelastic Scattering from Surfaces, Interfaces and Thin Films
 - Phonons in Thin Films
 - Surface Melting
 - Surface Layering in Liquid Metals: Phonon Spectrum
 - Surface-related Inelastic Precursor of Structural Phase Transitions
 - X-ray Scattering from Laser-induced Charge Densities
 - Inelastic X-ray Scattering Spectroscopy
 - Spectroscopy with Coherent X-Rays
 - <u>Status and Applications</u>
 - Dynamics of Disordered Systems
 - Dynamic Structure Factor of Liquids
 - Crystal growth and surfaces
 - Rapid Solidification
 - <u>Structural Studies of Disordered Biological Systems</u>
 - Expected Impact
- Microscopy and Imaging with Coherent X-rays
- Quantum Optics
 - Introduction
 - Examples of Applications
 - Precise Frequency Shifts of X-rays
 - Spontaneous Parametric Conversion of X-ray Photons, Bell's Inequality, Two-photon Interference
 - Spectroscopy on Muonic Hydrogen
 - Nonclassical States of Light
 - <u>Atom Beam Interferometry</u>













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